

P u b l i k a č n ý s e m i n á r

P. Chauhan:

Effect of temperature and carrier gas on the properties of thick $\text{In}_x\text{Al}_{1-x}\text{N}$ layer
Applied Surface Science

Z. Zápražný:

Characterization of the chips generated by the nanomachining of germanium for X-ray crystal optics
International Journal of Advanced Manufacturing Technology

K. Fröhlich:

Hafnium oxide and tantalum oxide based resistive switching structures for realization of minimum and maximum functions
Journal of Applied Physics

J. Kováč:

AC losses of Rutherford MgB_2 cables made by powder-in-tube and internal magnesium diffusion processes
Superconductor Science and Technology

M. Ťapajna:

Impact of oxide/barrier charge on threshold voltage instabilities in AlGaIn/GaN metal-oxide-semiconductor heterostructures
Materials Science in Semiconductor Processing

Čas: 8. marec 2019 o 10:00 hod. Miesto: veľká zasadačka EIÚ SAV, miestnosť 101